

**Search Notes**

Application No.

10/647,784

Examiner

D. Rutledge

Applicant(s)

KURT ET AL.

Art Unit

2851

**SEARCHED**

Class	Subclass	Date	Examiner
355	53, 67-71	9/21/2004	DR
427	216,336	9/21/2004	DR
427	248.1	9/21/2004	DR
427	402	9/21/2004	DR
430	5	9/21/2004	DR
378	35, 84	9/21/2004	DR

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
oxidation or rust, prevent\$3 or prohibit\$3 or preclud\$3, mirror or optic\$3, multilayer, mo or molybdenum,	9/21/2004	DR
si or silicon, interlayer or intermediate adj layer, c or carbon, top or cap or capping, ru or ruthenium	9/21/2004	DR
thickness, nm or nanometer or angstrom or A	9/21/2004	DR